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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/759,857	01/17/2004	Boris Kobrin	MS-001 8766	
7590 06/29/2005		·	EXAMINER	
Shirley L. Church, Esq.			LUND, JEFFRIE ROBERT	
P.O. Box 61929 Sunnyvale, CA 94088			ART UNIT .	PAPER NUMBER
			1763	
		•	DATE MAILED: 06/29/2005	ς .

Please find below and/or attached an Office communication concerning this application or proceeding.

		8				
-	Application No.	Applicant(s)				
	10/759,857	KOBRIN ET AL.				
Office Action Summary	Examiner	Art Unit				
	Jeffrie R. Lund	1763				
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply						
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply If NO period for reply is specified above, the maximum statutory period w - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	86(a). In no event, however, may a reply be time within the statutory minimum of thirty (30) days will apply and will expire SIX (6) MONTHS from cause the application to become ABANDONE	nely filed s will be considered timely. the mailing date of this communication. O (35 U.S.C. § 133).				
Status						
1) Responsive to communication(s) filed on 23 June 2004.						
2a) ☐ This action is FINAL . 2b) ☑ This action is non-final.						
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is						
closed in accordance with the practice under E	x parte Quayle, 1935 C.D. 11, 45	3 O.G. 213.				
Disposition of Claims	,	•				
 4) Claim(s) 1-25 is/are pending in the application. 4a) Of the above claim(s) 11-25 is/are withdraw 5) Claim(s) is/are allowed. 6) Claim(s) 1-10 is/are rejected. 7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction and/or 	n from consideration.					
Application Papers						
9) The specification is objected to by the Examiner 10) The drawing(s) filed on 12 March 2004 is/are: a Applicant may not request that any objection to the of Replacement drawing sheet(s) including the correction 11) The oath or declaration is objected to by the Examiner	a) accepted or b) objected to drawing(s) be held in abeyance. See on is required if the drawing(s) is obj	ected to. See 37 CFR 1.121(d).				
Priority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority documents 2. Certified copies of the priority documents 3. Copies of the certified copies of the priority application from the International Bureau * See the attached detailed Office action for a list of	s have been received. s have been received in Application ity documents have been received (PCT Rule 17.2(a)).	on No ed in this National Stage				
American (III)						
Attachment(s) 1) Notice of References Cited (PTO-892)	4) Interview Summary	(PTO-413)				
2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)	Paper No(s)/Mail Da					

Paper No(s)/Mail Date 3/04.

6) Other: _

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DETAILED ACTION

Election/Restrictions

- 1. Restriction to one of the following inventions is required under 35 U.S.C. 121:
 - I. Claims 1-10, drawn to an apparatus, classified in class 118, subclass 715.
- II. Claims 11-25, drawn to a method, classified in class 427, subclass 248.1.

 The inventions are distinct, each from the other because of the following reasons:
- 2. Inventions of Group II and Group I are related as process and apparatus for its practice. The inventions are distinct if it can be shown that either: (1) the process as claimed can be practiced by another materially different apparatus or by hand, or (2) the apparatus as claimed can be used to practice another and materially different process. (MPEP § 806.05(e)). In this case the apparatus as claimed can be used to practice another and materially different process such as etching.
- 3. Because these inventions are distinct for the reasons given above and have acquired a separate status in the art as shown by their different classification, restriction for examination purposes as indicated is proper.
- 4. During a telephone conversation with Shirley Church on December 16, 2004 a provisional election was made without traverse to prosecute the invention of Group I, claims 1-10. Affirmation of this election must be made by applicant in replying to this Office action. Claims 11-25 are withdrawn from further consideration by the examiner, 37 CFR 1.142(b), as being drawn to a non-elected invention.
- 5. Applicant is reminded that upon the cancellation of claims to a non-elected invention, the inventiorship must be amended in compliance with 37 CFR 1.48(b) if one

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or more of the currently named inventors is no longer an inventor of at least one claim remaining in the application. Any amendment of inventorship must be accompanied by a request under 37 CFR 1.48(b) and by the fee required under 37 CFR 1.17(i).

Claim Rejections - 35 USC § 112

- 6. The following is a quotation of the second paragraph of 35 U.S.C. 112:

 The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.
- 7. Claims 1-10 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

Claim 1 includes the limitations "at least one device which controls precursor vapor flow from said precursor container into said precursor vapor reservoir" (lines 9 and 10); "a device which controls vapor flow from said precursor container into said precursor vapor reservoir" (lines 14 and 15); and a device which controls precursor vapor flow into said precursor vapor reservoir upon receipt of a signal from said first process controller" (lines 17 and 18). It is not clear if these are three different devices of if they are all the same device. The drawings only disclose one device (valve 132) to control the flow between the precursor container and the precursor reservoir.

Claim 1 recites the limitation "the first process controller" in line 18. There is insufficient antecedent basis for this limitation in the claim.

Claim Rejections - 35 USC § 102

8. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

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A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

9. Claims 1, 2, 9/1, 9/2, and 10 are rejected under 35 U.S.C. 102(b) as being anticipated by Hatano, US Patent 5,989,345.

Hatano teaches a deposition apparatus that includes: a precursor container 22 heated by a heater 28; precursor vapor reservoir 32; a valve 38D which controls the precursor flow to the precursor vapor reservoir 32 from the precursor container; a pressure sensor 60; a controller which receives information form the pressure sensor and controls the valve to when the desired pressure is reached; a process chamber 18; and a valve 38E that controls the precursor flow into the process chamber. The specific thickness of the coating is an intended use of the apparatus, and the apparatus of Hatano is inherently capable of depositing a coating of the thickness claimed. (Entire document, specifically, figure 1)

Claim Rejections - 35 USC § 103

- 10. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 11. This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation

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under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

12. Claims 2-8, 9/4 and 9/5 rejected under 35 U.S.C. 103(a) as being unpatentable over Hatano, US Patent 5,989,345.

Hatano was discussed above.

Hatano differs from the present invention in that Hatano does not teach a plurality of process gas supply systems for other precursors and catalysts.

The motivation for duplicating the gas supply system of Hatano is to enable

Hatano to supply multiple precursors and other gases such as catalysis. Furthermore, it
has been held that the duplication of parts is obvious (see In re Harza 124 USPQ 378).

Therefore it would have been obvious to one of ordinary skill in the art at the time the invention was made to duplicate the gas supply system of Hatano to supply multiple precursors and catalysts to the processing chamber.

13. Claims 1-10 rejected under 35 U.S.C. 103(a) as being unpatentable over Sneth et al, US Patent 6,503,330 B1, in view of Hatano, US Patent 5,989,345.

Sneth et al teaches a deposition system that has a plurality of precursors and catalysts located in chemical manifold section 40 and 41.

Sneth et al differs from the present invention in that Sneth et al does not teach that each of the precursor or catalyst sources in the chemical manifold sections have a precursor container heated by a heater; precursor vapor reservoir; a valve which

controls the precursor flow to the precursor vapor reservoir from the precursor container; a pressure sensor; a controller which receives information form the pressure sensor and controls the valve to when the desired pressure is reached; and a valve that controls the precursor flow into the process chamber.

Hatano teaches a precursor container 22 heated by a heater 28; precursor vapor reservoir 32; a valve 38D which controls the precursor flow to the precursor vapor reservoir 32 from the precursor container; a pressure sensor 60; a controller which receives information form the pressure sensor and controls the valve to when the desired pressure is reached; a process chamber 18; and a valve 38E that controls the precursor flow into the process chamber.

The motivation for adding the gas supply system of Hatano to the apparatus of Sneth et al is provide a specific gas supply system for the apparatus as required by Sneth et al but only generically described by Sneth et al.

Therefore it would have been obvious to one of ordinary skill in the art at the time the invention was made to add the gas supply system of Hatano to the apparatus of Sneth et al.

Conclusion

14. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. The cited art teaches the technological background of the invention. The cited art contains patents that could be used to reject the claims under 35 USC § 102 or 103. These rejections have not been made because they do not provide any additional or different teachings, and if they were applied, would have

resulted in an undue multiplication or references. (See MPEP 707.07(g))

15. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Jeffrie R. Lund whose telephone number is (571) 272-1437. The examiner can normally be reached on Monday-Thursday (6:30 am-6:00pm).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Parviz Hassanzadeh can be reached on (571) 272-1435. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

> Jeffrie R. Lund **Primary Examiner** Art Unit 1763

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JRL 6/27/05